



etherea  
light-source solutions





ipl-sq

EPK  
13.03.09  
antes

EPK  
16.03.09  
depois

filtro 640 nm, 16 J/cm<sup>2</sup>, 30 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 17 J/cm<sup>2</sup>, 30 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES

BT  
24-08-09

MAO  
24-08-10

filtro 640 nm, 17 J/cm<sup>2</sup>, 30 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 16 J/cm<sup>2</sup>, 30 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 17 J/cm<sup>2</sup>, 20 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 16 J/cm<sup>2</sup>, 30 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES









**INDUSTRA**  
TECHNOLOGIES

**INDUSTRA**  
TECHNOLOGIES

filtro 540 nm, 18 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



INDUSTRA  
TECHNOLOGIES



INDUSTRA  
TECHNOLOGIES

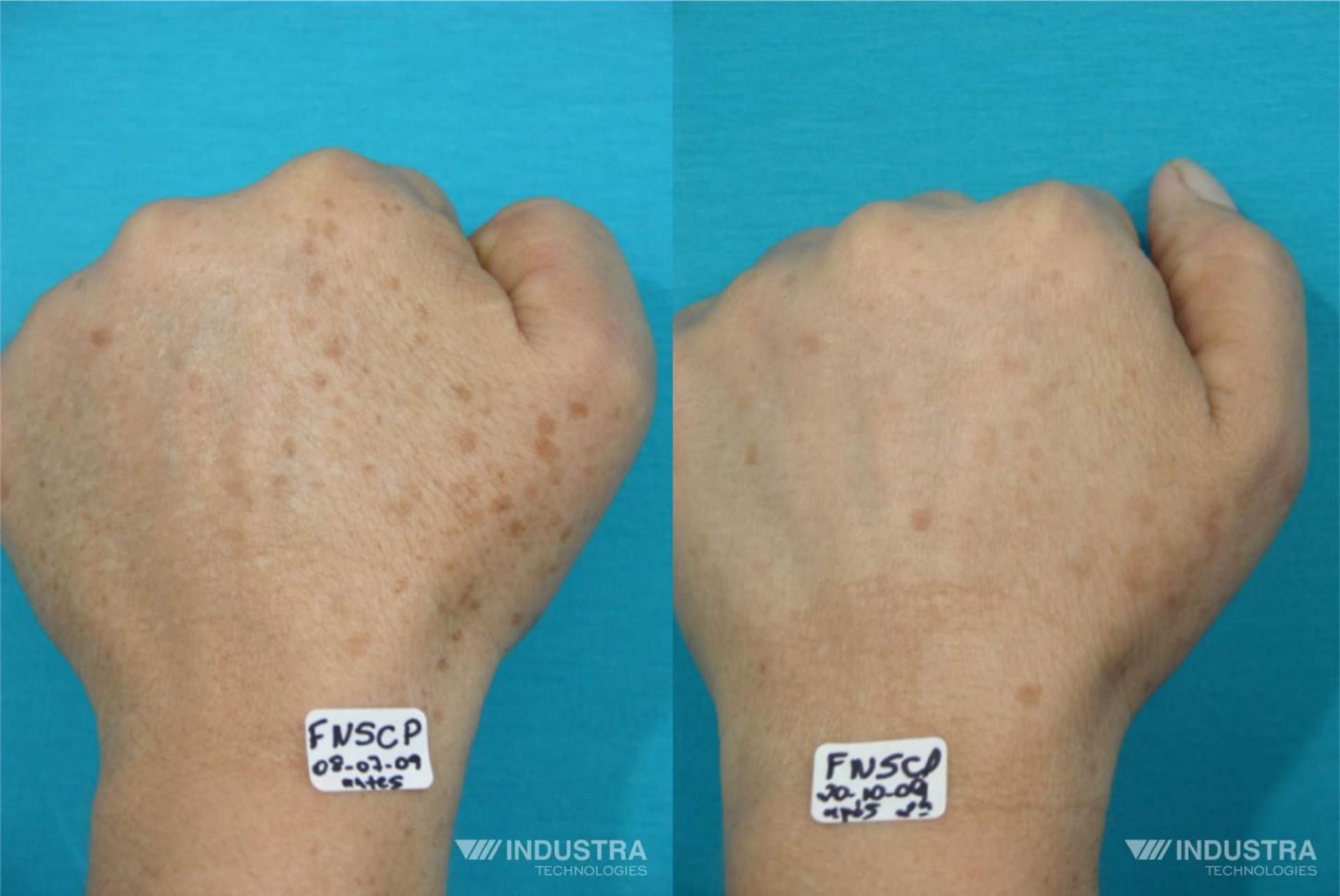
filtro 540 nm, 19 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 540 nm, 18 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS- INDUSTRA TECHNOLOGIES



filtro 540 nm, 18 J/cm<sup>2</sup>, 15 ms

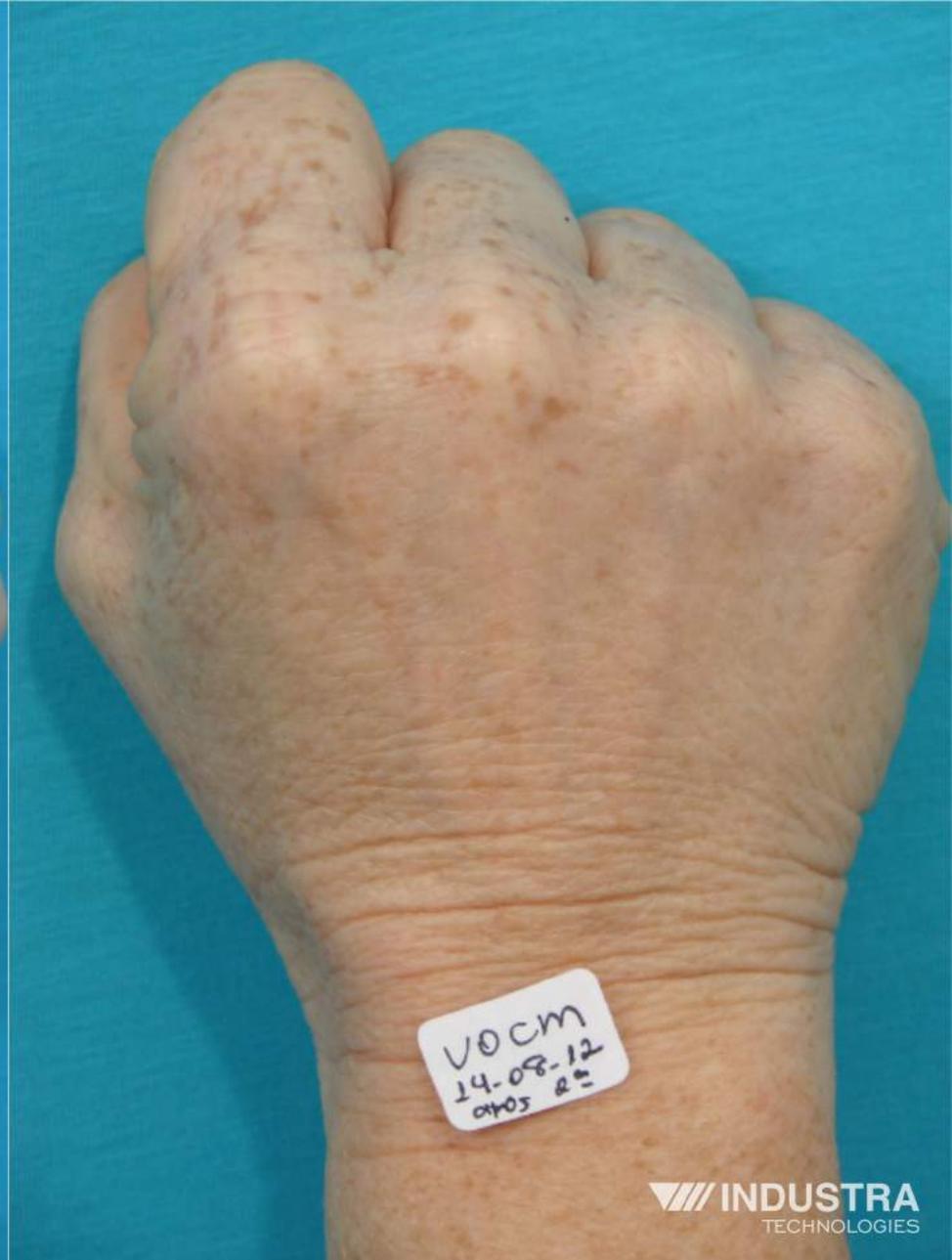
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES







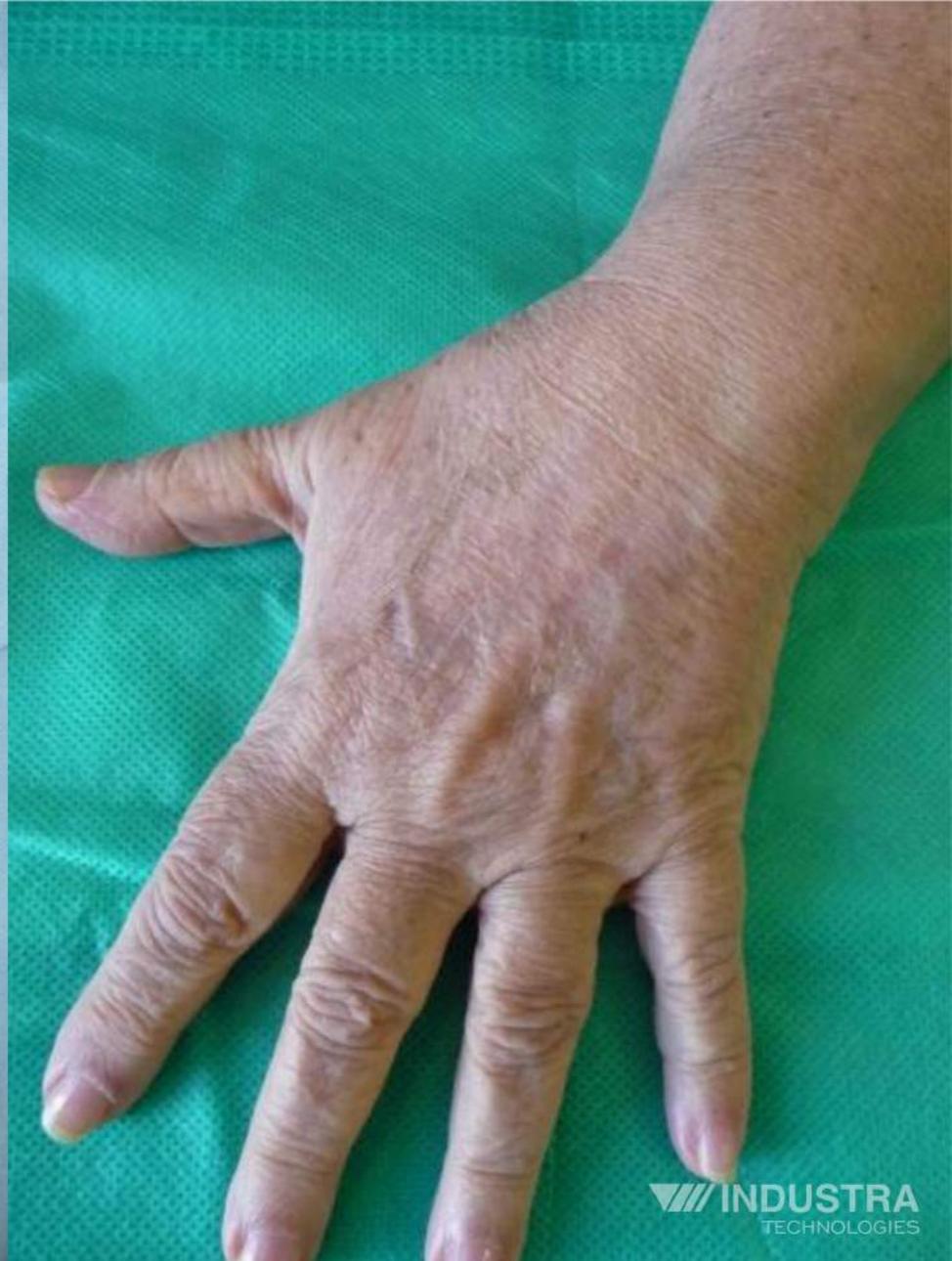
filtro 540 nm, 20 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Marcio Serra. Rio de Janeiro, RJ. Brasil.

 **INDUSTRA**  
TECHNOLOGIES

 **INDUSTRA**  
TECHNOLOGIES

 **INDUSTRA**  
TECHNOLOGIES



filtro 540 nm, 20 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Marcio Serra. Rio de Janeiro, RJ. Brasil



filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Maisa Pamponet. Salvador, BA. Brasil



filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Maisa Pamponet. Salvador, BA. Brasil



 **INDUSTRA**  
TECHNOLOGIES



 **INDUSTRA**  
TECHNOLOGIES

CORTESIA: Flávia Ramos. Campo dos Goytacazes, RJ. Brasil.

 **INDUSTRA**  
TECHNOLOGIES



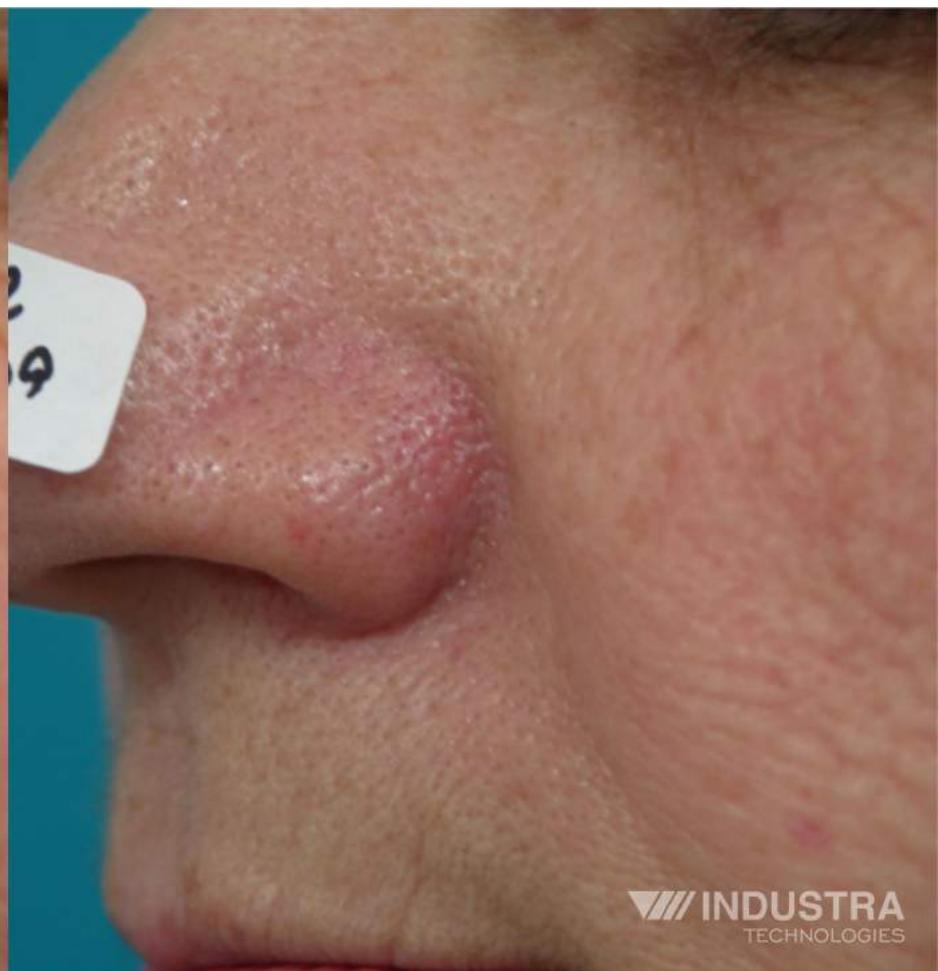
**INDUSTRA**  
TECHNOLOGIES



**INDUSTRA**  
TECHNOLOGIES

filtro 540 nm, 16 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 540 nm, 20 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES









 **INDUSTRA**  
TECHNOLOGIES



 **INDUSTRA**  
TECHNOLOGIES







filtro 540 nm, 17 J/cm<sup>2</sup>, 10 ms



filtro 540 nm, 15 J/cm<sup>2</sup>, 20 ms

**CORTESIA:** Lilian Braga. Sorocaba, SP. Brasil.

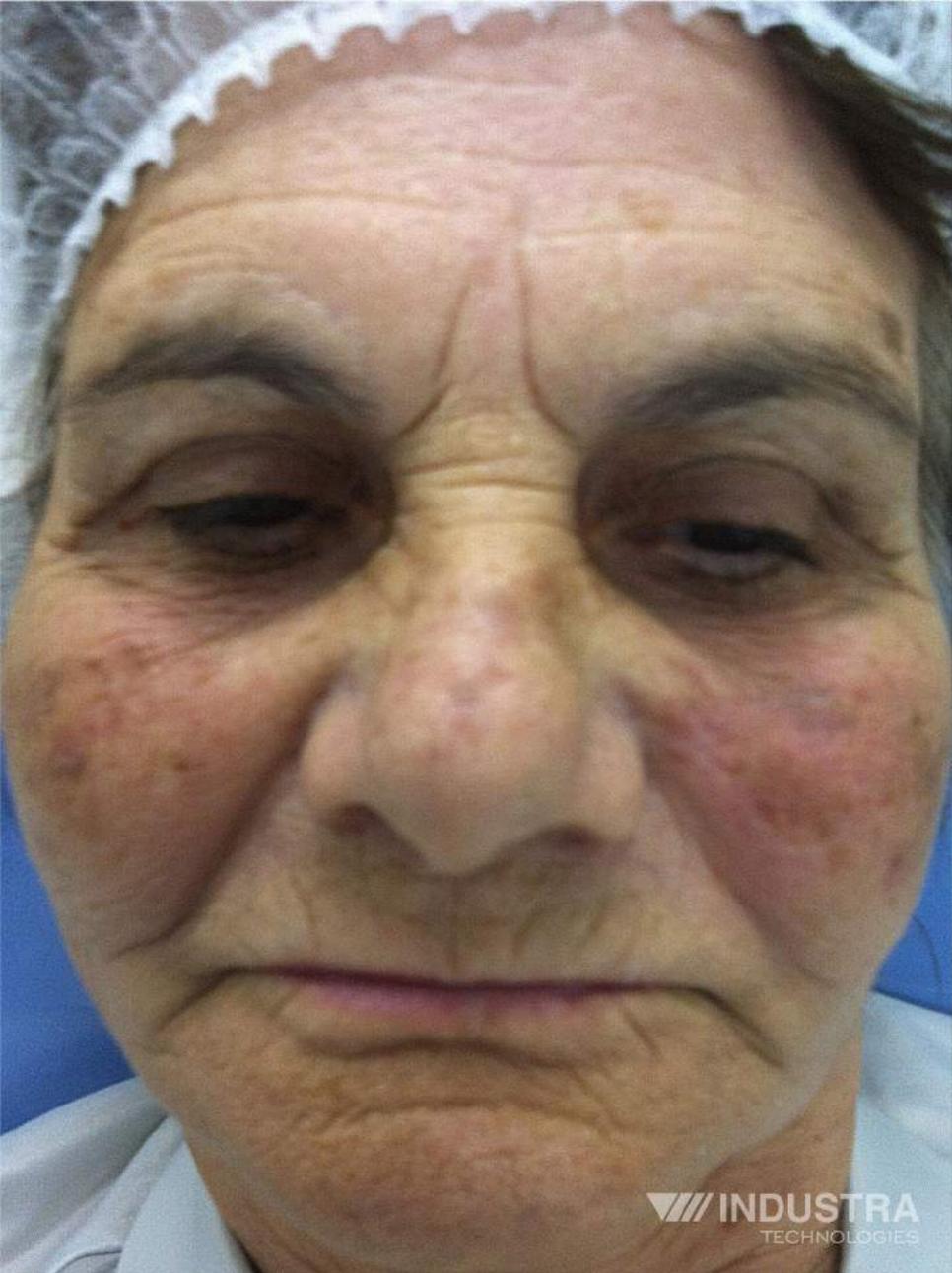


INDUSTRA  
TECHNOLOGIES

INDUSTRA  
TECHNOLOGIES

filtro 540 nm, 14/15 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Fernando Mandelli. Blumenau, SC. Brasil.



filtro 540 nm, 14/15 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Fernando Mandelli. Blumenau, SC



filtro 540 nm, 14/15 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Fernando Mandelli. Blumenau, SC. Brasil.



**INDUSTRA**  
TECHNOLOGIES

**INDUSTRA**  
TECHNOLOGIES

filtro 540 nm, 14 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



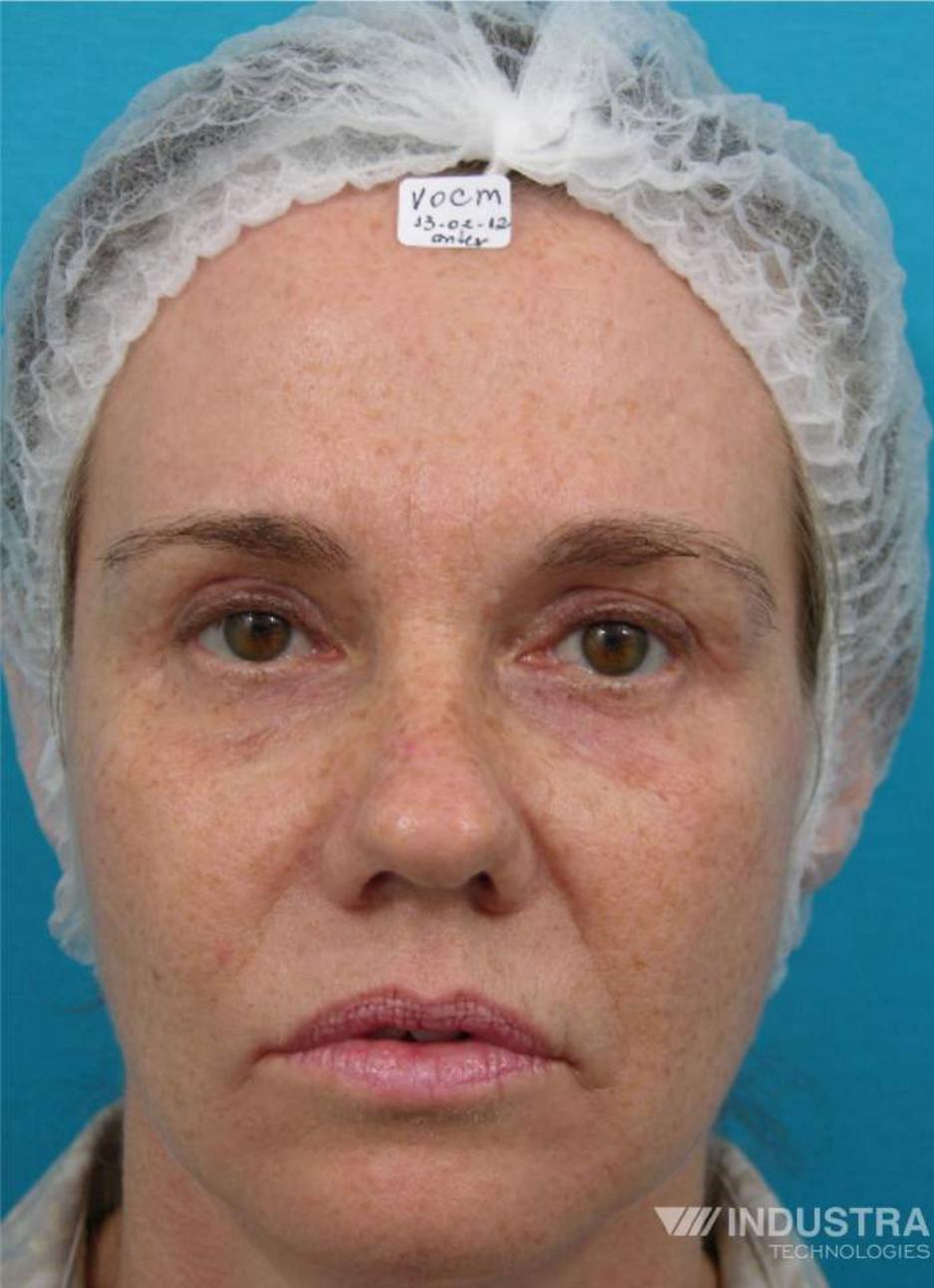
 **INDUSTRA**  
TECHNOLOGIES



 **INDUSTRA**  
TECHNOLOGIES

filtro 540 nm, 14 J/cm<sup>2</sup>, 15 ms

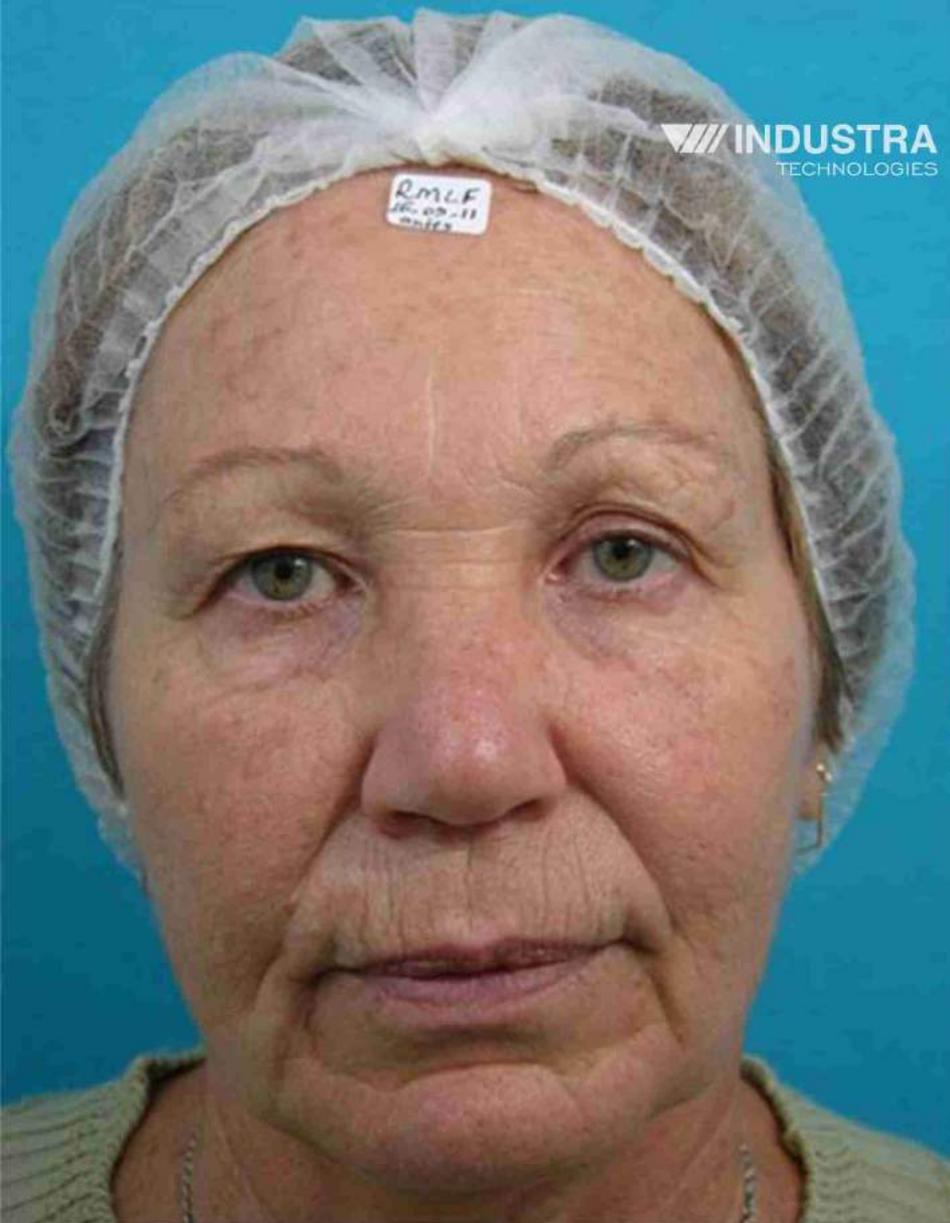
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



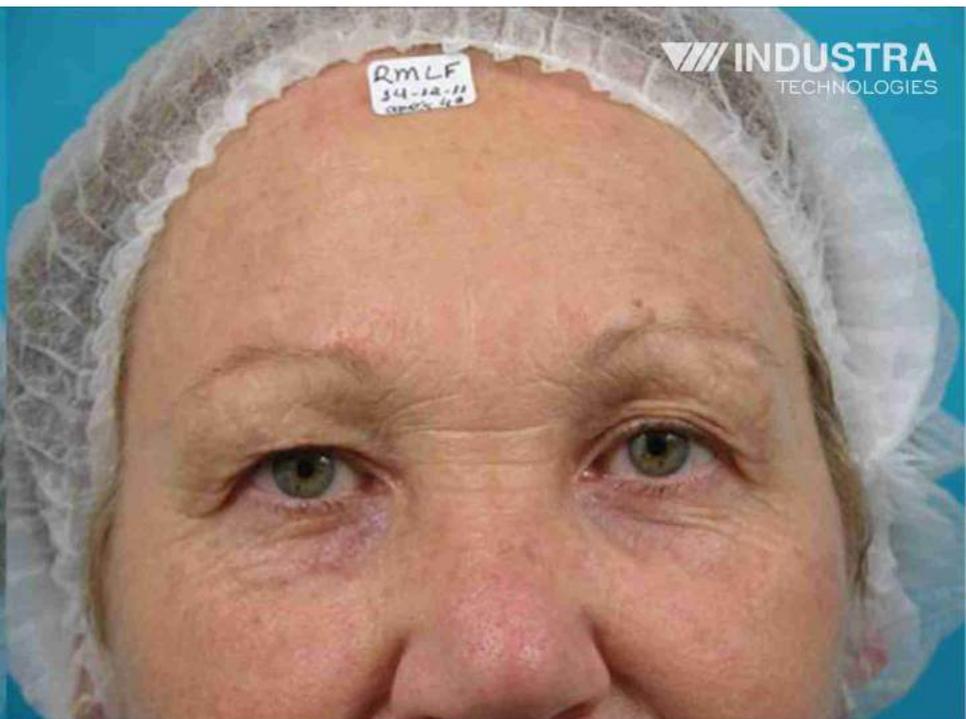
**INDUSTRA**  
TECHNOLOGIES



**INDUSTRA**  
TECHNOLOGIES



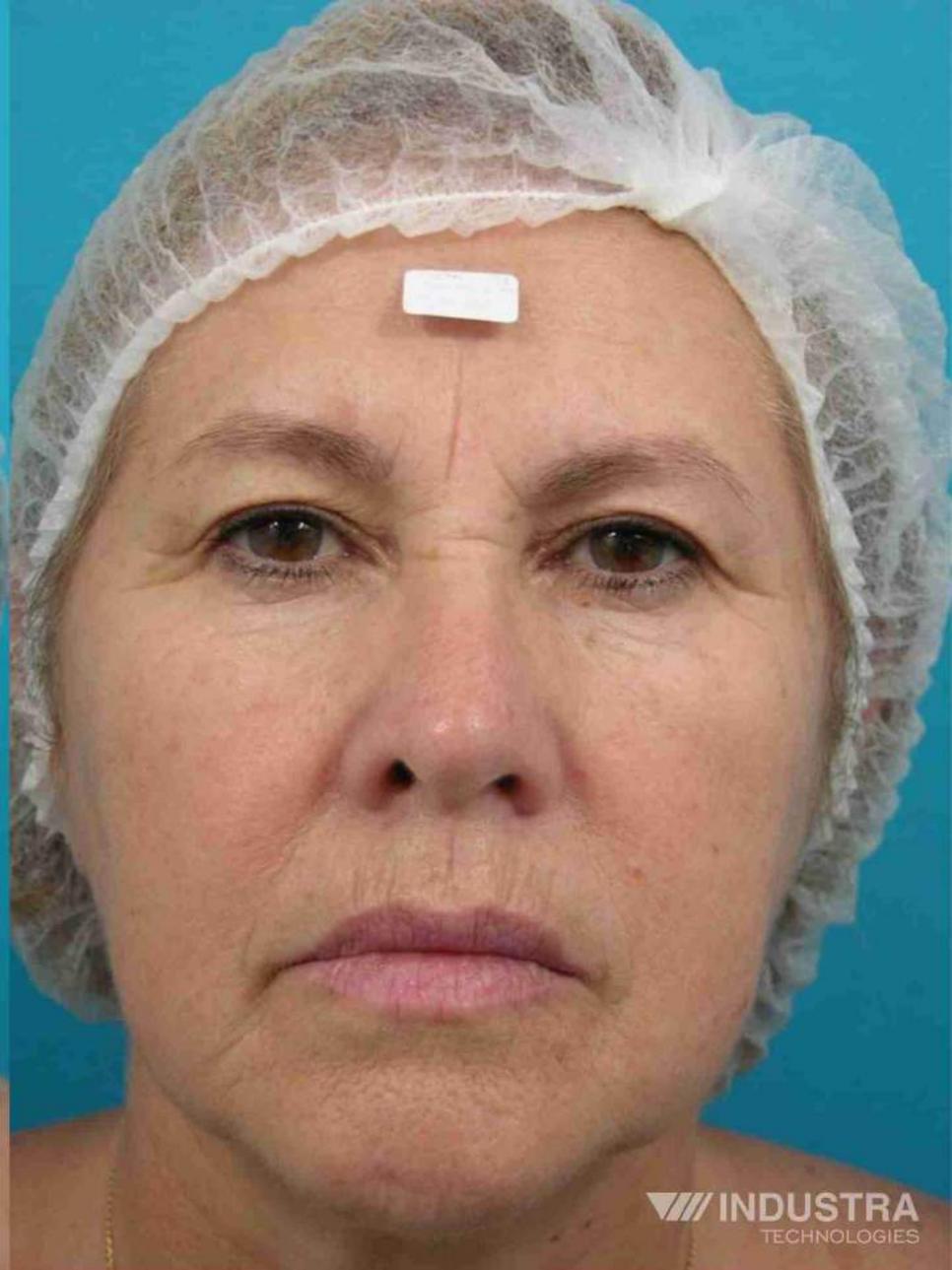
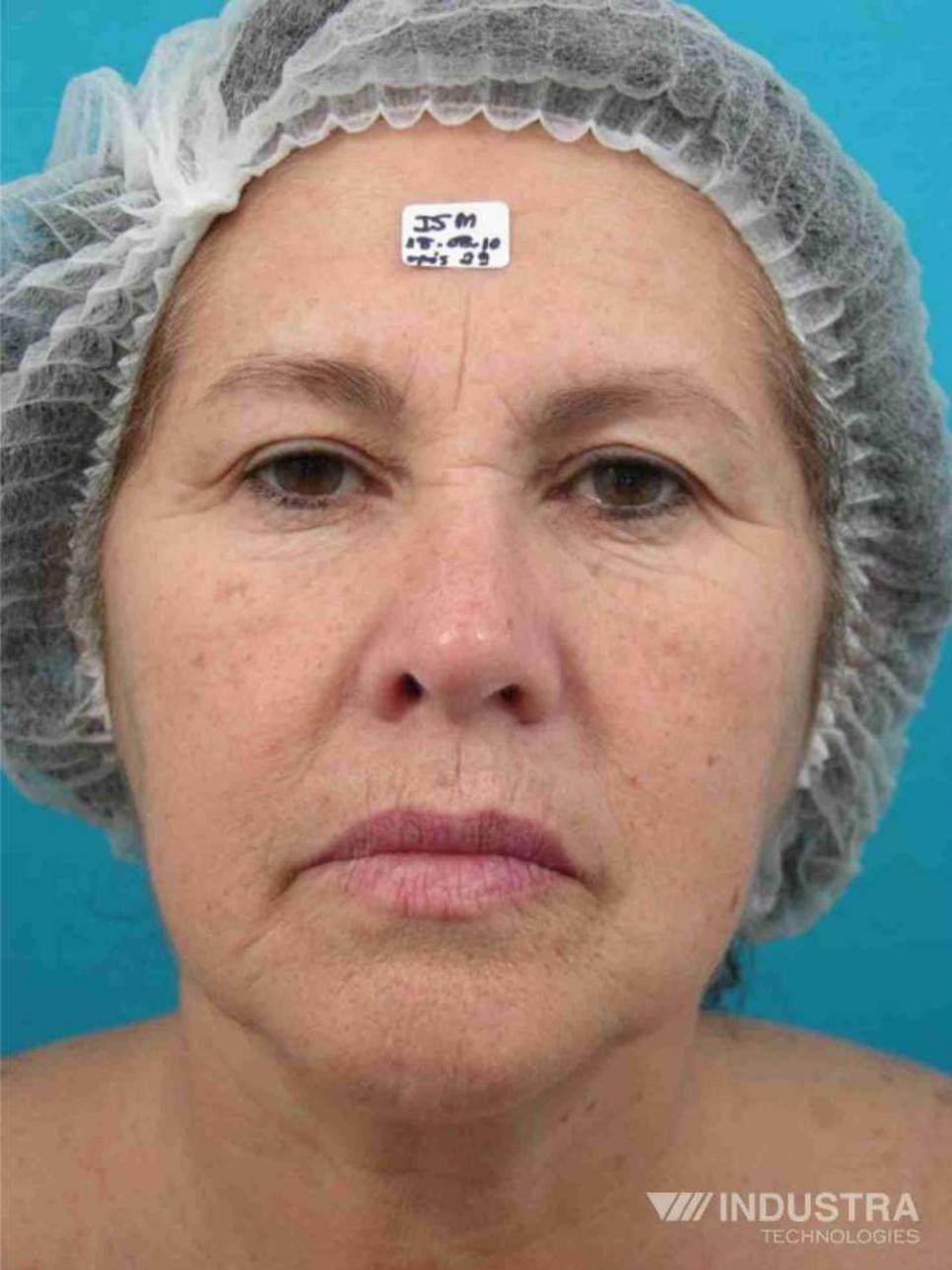
filtro 540 nm, 14 J/cm<sup>2</sup>, 15 ms, AR5%; filtro 640 nm, 12 J/cm<sup>2</sup>, 40 ms  
filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms, AR5%; filtro 640 nm, 12 J/cm<sup>2</sup>, 30 ms + VT 540 nm, 18 J/cm<sup>2</sup>, 15 ms, AR 5%  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 540 nm, 14 J/cm<sup>2</sup>, 15 ms, AR5%; filtro 640 nm, 12 J/cm<sup>2</sup>, 40 ms  
filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms, AR5%; filtro 640 nm, 12 J/cm<sup>2</sup>, 30 ms + VT 540 nm, 18 J/cm<sup>2</sup>, 15 ms, AR 5%  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 12 J/cm<sup>2</sup>, 30 ms + VT, 18 J/cm<sup>2</sup>, 15 ms, AR 5%  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES





filtro 640 nm, 12 J/cm<sup>2</sup>, 100 ms; filtro 400 nm, 10 J/cm<sup>2</sup>, 30 ms  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



**INDUSTRA**  
TECHNOLOGIES



**INDUSTRA**  
TECHNOLOGIES

filtro 640 nm, 12 J/cm<sup>2</sup>, 100 ms; filtro 400 nm, 10 J/cm<sup>2</sup>, 30 ms  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 12 J/cm<sup>2</sup>, 100 ms; filtro 400 nm, 8 J/cm<sup>2</sup>, 30 ms  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 12 J/cm<sup>2</sup>, 100 ms; filtro 400 nm, 8 J/cm<sup>2</sup>, 30 ms  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



INDUSTRA  
TECHNOLOGIES



INDUSTRA  
TECHNOLOGIES

filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms; filtro 540 nm, 10 J/cm<sup>2</sup>, 20 ms; filtro 540 nm, 14 J/cm<sup>2</sup>, 10 ms

**CORTESIA:** Carlos Alberto Ferreira Jorge. Campinas, SP. Brasil.



filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms; filtro 540 nm, 10 J/cm<sup>2</sup>, 20 ms; filtro 540 nm, 14 J/cm<sup>2</sup>, 10 ms

**CORTESIA:** Carlos Alberto Ferreira Jorge. Campinas, SP. Brasil.



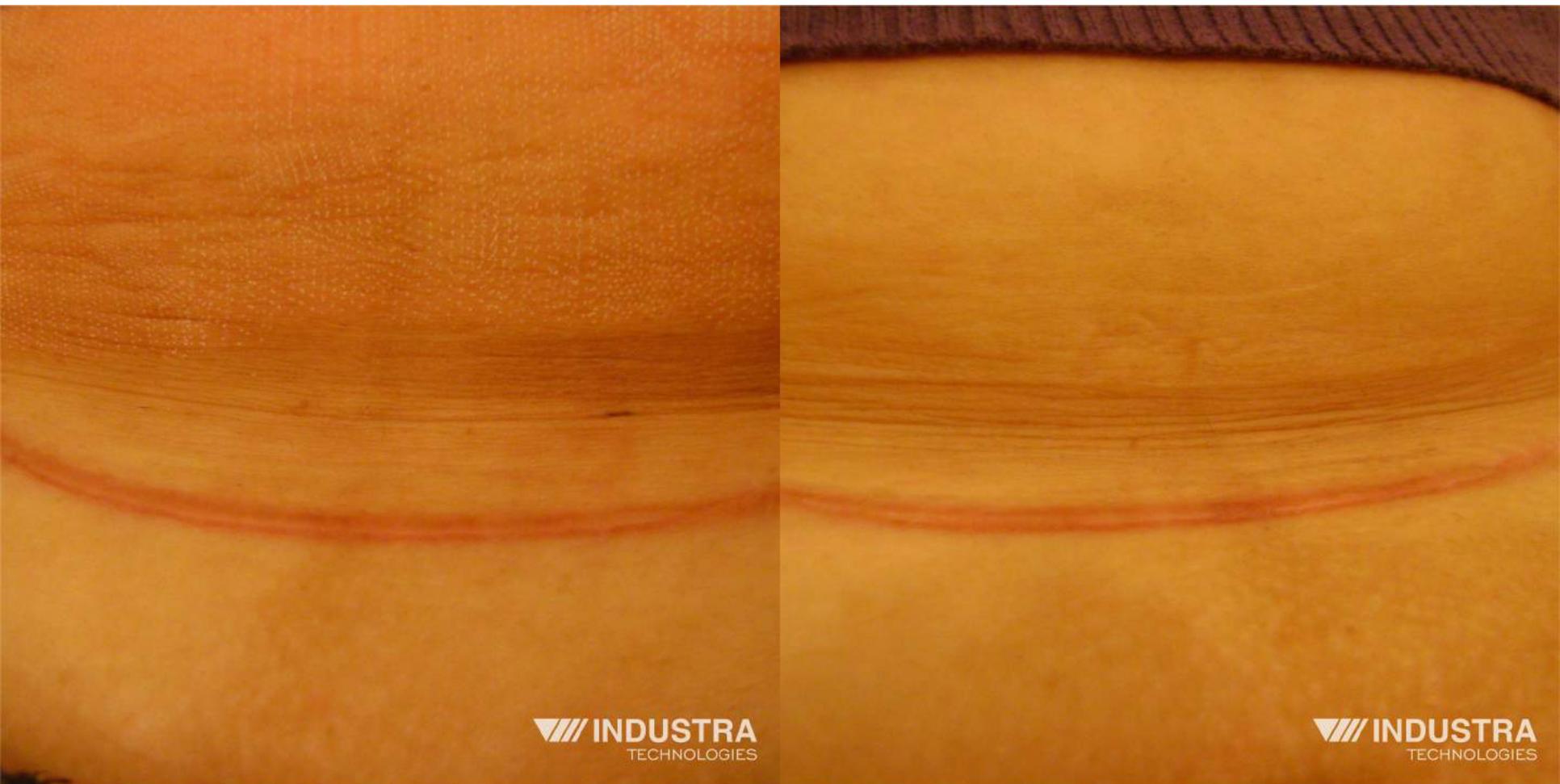
**INDUSTRA**  
TECHNOLOGIES



**INDUSTRA**  
TECHNOLOGIES

filtro 540 nm, 15 J/cm<sup>2</sup>, 30 ms; filtro 540 nm, 14 J/cm<sup>2</sup>, 15 ms; filtro 540 nm, 16 J/cm<sup>2</sup>, 30 ms;

**CORTESIA:** Fabiana Wanick. Niterói, RJ. Brasil.



filtro 540 nm, 14 J/cm<sup>2</sup>, 10 ms

**CORTESIA:** Sumaya Mattar. Juiz de Fora, MG



ipl-sq